

Materials List for:

Reactive Vapor Deposition of Conjugated Polymer Films on Arbitrary Substrates

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Materials

Name	Company	Catalog Number	Comments
3,4-Ethylenedioxythiophene, 97%	Sigma Aldrich	483028	
3,4-Propylenedioxythiophene, 97%	Sigma Aldrich	660485	
Thieno[3,2-b]thiophene, 95%	Sigma Aldrich	702668	
FeCl ₃ , 97%	Sigma Aldrich	157740	
Br ₂	Sigma Aldrich	207888	